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INFORMATION DISCLOSURE STATEMENT BY APPLICANT

Sheet

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of

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Application Number

Unassigned W/724,056.

Filing Date

December 1, 2003

First Named Inventor

Tetsuo KUNII

Group Art Unit

Unassigned	2811
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Examiner Name

~~Unassigned~~ HUNG VU

Attorney Docket Number

402887/AOYAMA

Examiner
Initials

Doc. No.

Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number (s), publisher, city and/or country where published.

Translation

Yes:

 No^{++}
$$V_n$$

A 1

LOKE et al., "Copper Drift in Low-K Polymer Dielectrics for ULSI Metallization," 1998 Symposium on VLSI Tech., June 9-11, 1998, Honolulu, HI.

V_n

A2

WEB PAGE: Ireland Integrated Circuit Technology Research Institute NMRC, pp. 1-2, 10 October 2003.

**Examiner
Signature**

HUNG VU

Date Considered

01/28/05

- * A concise statement of relevance is being submitted in lieu of a translation. 37 CFR 1.98(a)(3).